

# HyMARC Seedling: ALD (Atomic Layer Deposition) Synthesis of Novel Nanostructured Metal Borohydrides

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DOE Hydrogen and Fuel Cells Program  
2020 Annual Merit Review and Peer Evaluation Meeting

Project ID #ST143

# Overview

## Timeline and Budget

- Project start date: 9/15/2017\*
- Project end date: 3/31/2021
- FY18 DOE funding: \$250k
- FY19 planned DOE funding: \$375k
- FY20 planned DOE funding: \$375k
- Total DOE funds received to date: \$1,000,000

\*Phase 3 Project Start: 4/1/2020

## Barriers

- **D** – Durability/Operability
- **E** – Charging/Discharging Rates
- **O** – Lack of understanding of hydrogen chemisorption

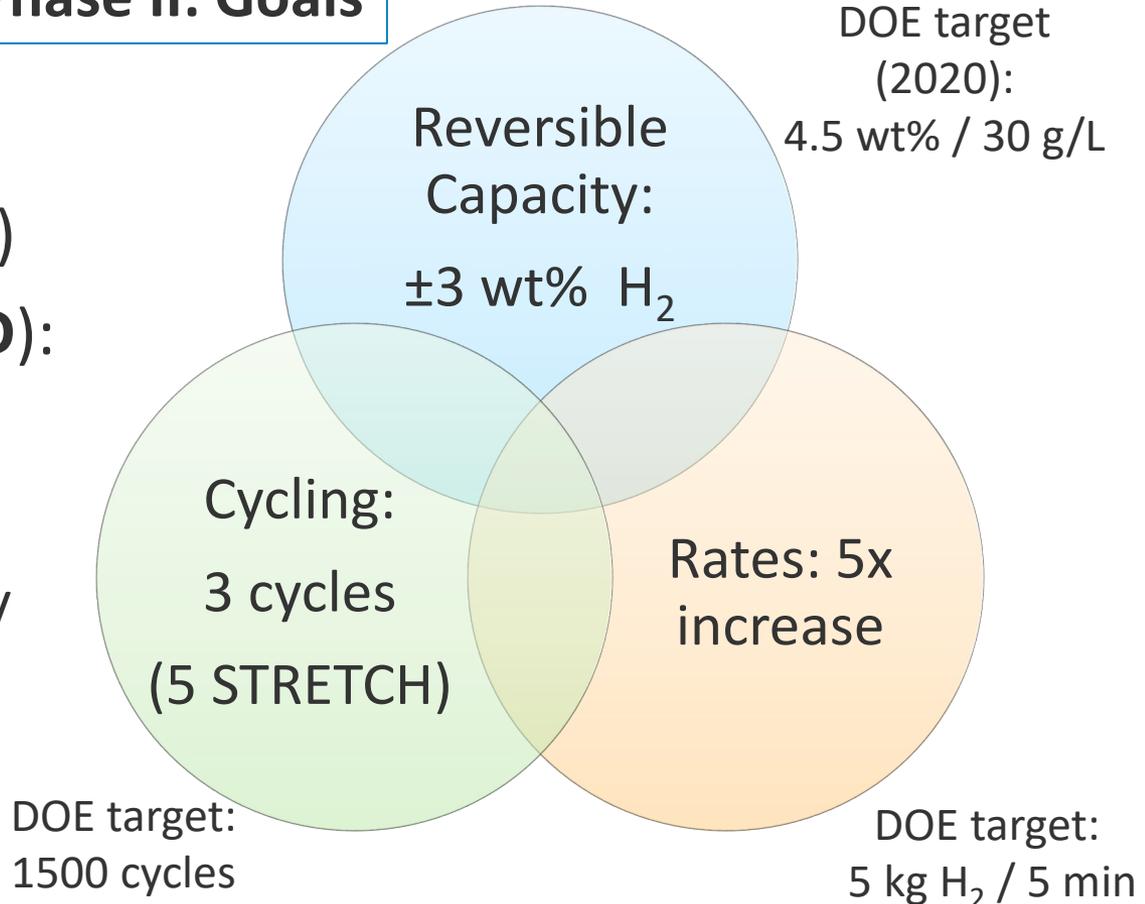
## Partners

H2Tech Consulting (cost share)  
Colorado School of Mines (cost share)  
HyMARC core team

# Relevance: Improve H<sub>2</sub> cycling and rates

- Project objectives: Improve **reversible capacity** and **rates** (charging/discharging)
- Reversibility (Barrier **D**):
  - Increase cycle life
- **Rates** (Barrier **E.**):
  - Reduce H<sub>2</sub> charging / discharging time
  - Reduce Operating Temperatures

## Phase II: Goals



Complex metal hydrides like Mg(BH<sub>4</sub>)<sub>2</sub>, NaAlH<sub>4</sub> possess a high hydrogen storage capacity, but insufficient charging/discharging rates and cyclability for DOE targets.

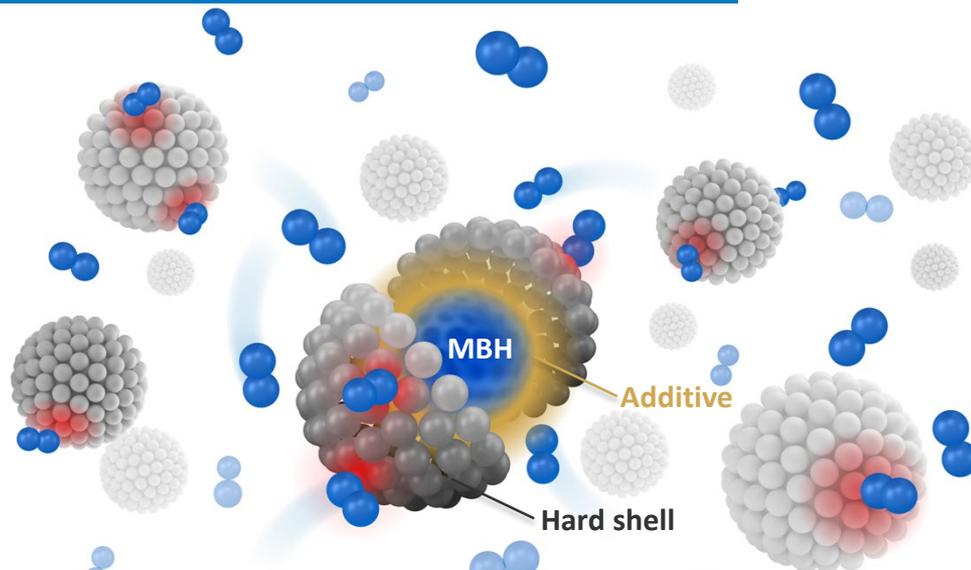
# Approach: Coatings by Atomic Layer Deposition (ALD)

**Concept:** Improve **reversible capacity** and **rates** by materials with:

- 1) Durable nanostructured phase
- 2) Chemical additives that enhance reaction rates

**How:** ALD coatings that:

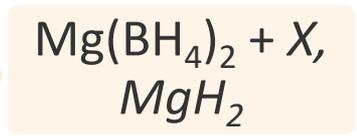
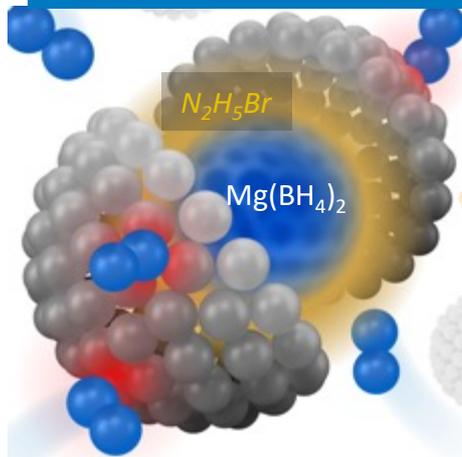
- **Protect.** Hard-permeable coating to retain nano-hydride for cyclability.
- **Catalyze.** Thin layer of additives that enhance rates.



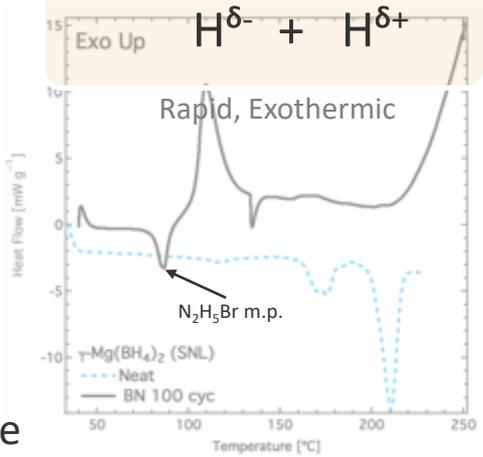
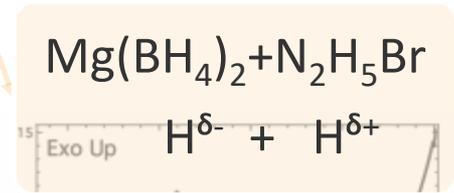
Milestone Description	Due Date (FY19)	Progress
Determine the discharging reaction mechanism	Q2	100 %
Determine charging rates/cyclability of neat $\text{Mg}(\text{BH}_4)_2$	Q1	100 %
Determine the charging reaction mechanism	Q3	100 %
Characterize coatings with advanced microscopy	Q4	100 %
Go/No-Go (GNG): Three $\text{H}_2$ cycles at 3 wt% $\text{H}_2$ + 5x improved charging. (Conditions: 250°C, 120 bar $\text{H}_2$ )	Q4	100 %

ALD coatings on  $\text{Mg}(\text{BH}_4)_2$  developed in FY18 improved discharge rates and showed potential for charging and cyclability.

# Accomplishments & Progress (A&P): Desorption mechanism for ALD BN/Mg(BH<sub>4</sub>)<sub>2</sub>

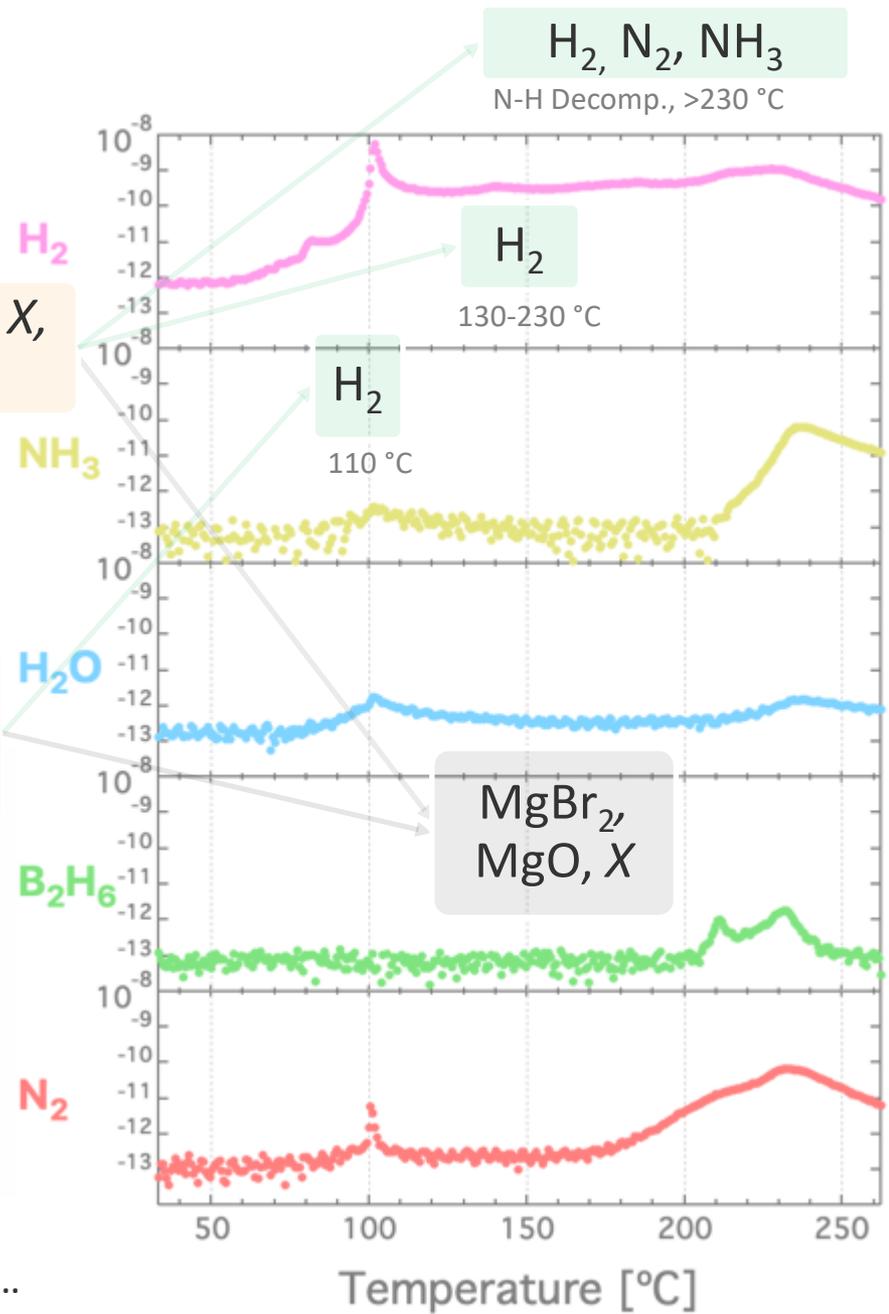


X Suppresses B<sub>2</sub>H<sub>6</sub>



X = Amorphous B-N-O...

- Rapid H<sub>2</sub> discharging results Mg(BH<sub>4</sub>)<sub>2</sub> + N<sub>2</sub>H<sub>5</sub>Br
- N<sub>2</sub>H<sub>5</sub>Br is a product of 'boron nitride' ALD
- Reaction driven by:
  - Heterolytic cleavage of B-H, N-H
  - Exothermic
- Irreversible Mg-O-Br-B-N products result



# A&P: High pressure recharge of ALD- $\text{Mg}(\text{BH}_4)_2$



Sandia  
National  
Laboratories

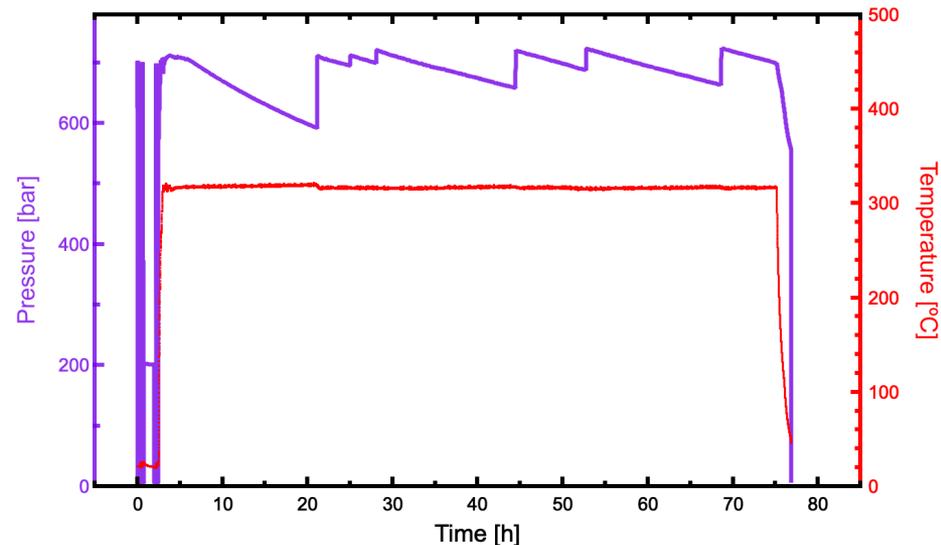


Photo: [hymarc.org](http://hymarc.org)

*Sandia high pressure charging apparatus can reach up to 1000 bar  $\text{H}_2$  and 400 °C.*

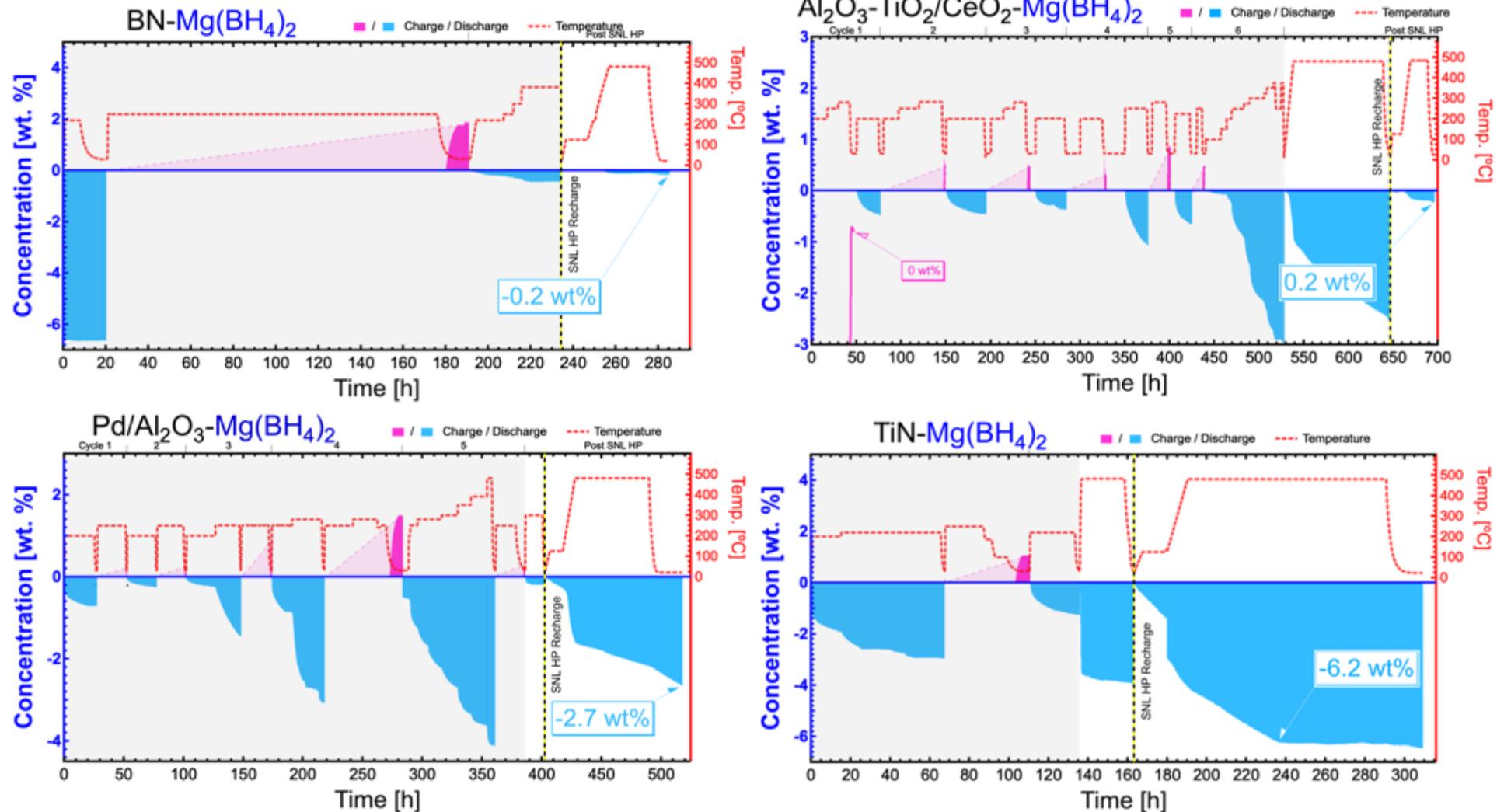
- High Pressure Recharge / Sandia National Lab:
  - Year 1 materials: ALD on  $\text{Mg}(\text{BH}_4)_2$ :
    - $\text{TiO}_2\text{-Al}_2\text{O}_3\text{-CeO}_2$ ,
    - $\text{Pd-Al}_2\text{O}_3$ ,
    - $\text{BN}$ ,  $\text{TiN}$
  - Pre-desorbed to high temperature
  - Recharge: 700 bar  $\text{H}_2$  / 320 °C / 72 h
  - All 4 samples recharged at the same time

SNL Recharge Conditions



*Recharge conditions of 700 bar  $\text{H}_2$  / 320°C / 72h should not result in  $\text{Mg}(\text{BH}_4)_2$  without active additives present.*

# A&P: Post High-Pressure Recharge Desorption



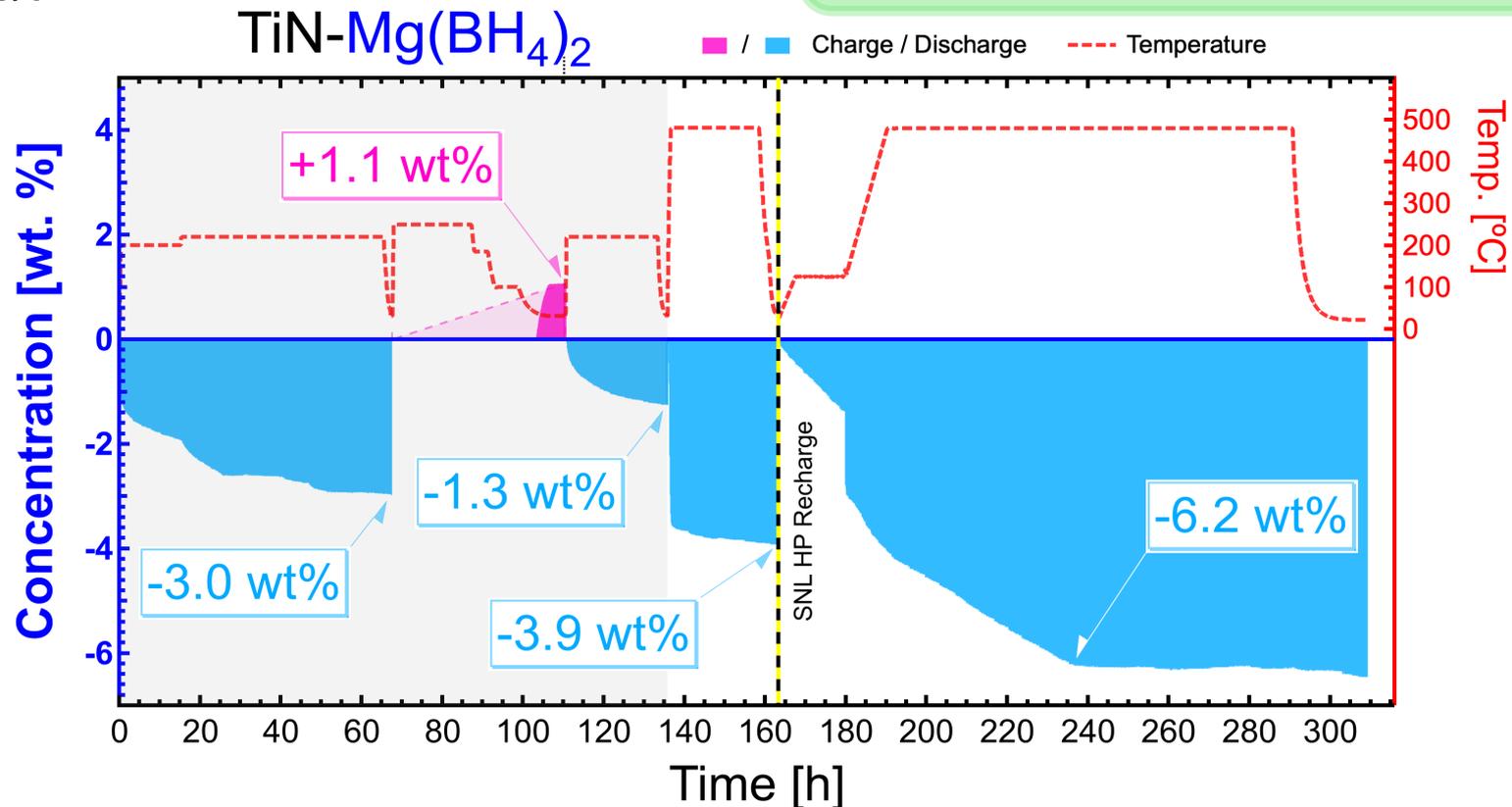
Shaded Area: Data From Phase 1

Clear Area: Results SNL HP charging

# A&P: Analyzing TiN/Mg(BH<sub>4</sub>)<sub>2</sub> results

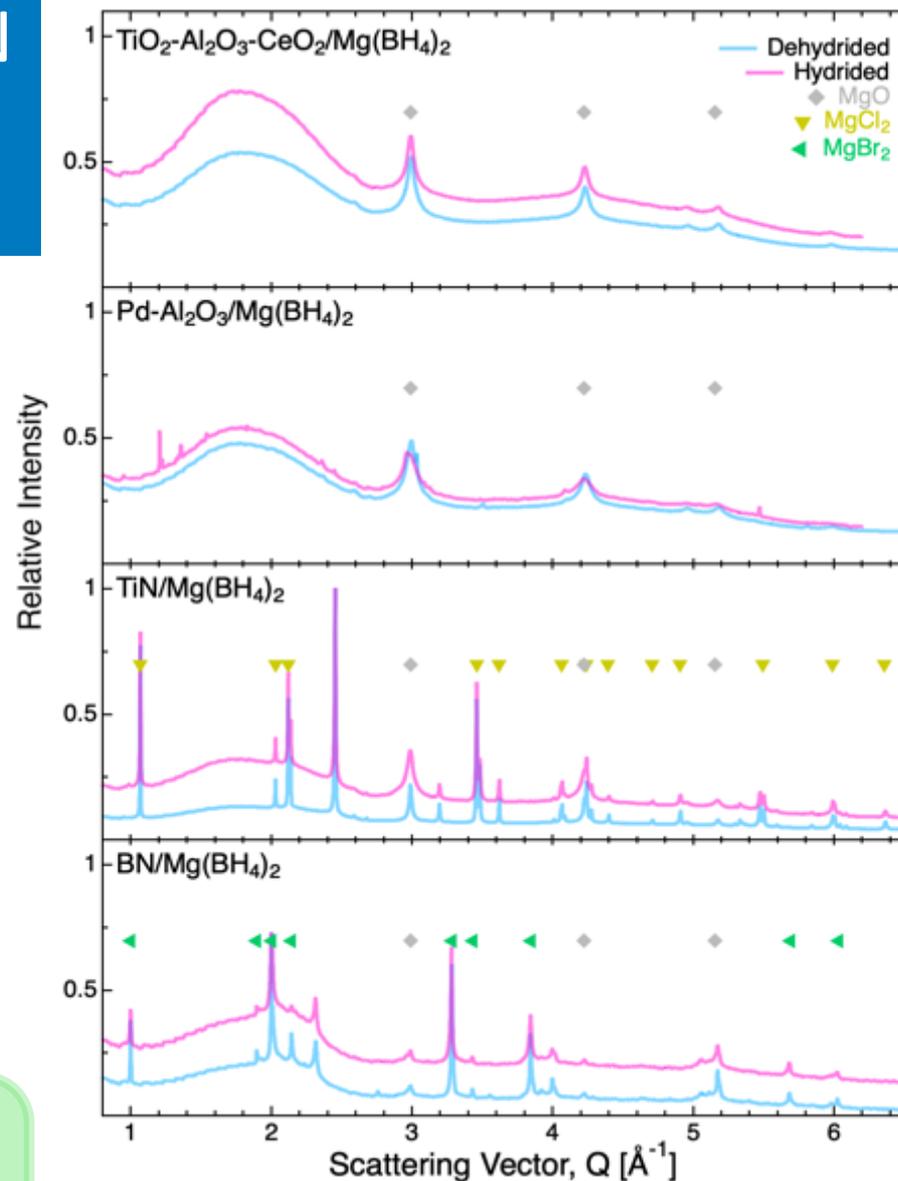
- Mg(BH<sub>4</sub>)<sub>2</sub>: 14.9 wt% H<sub>2</sub>
- $(-3.0) + (+1.1) + (-1.3) + (-3.9) = -7.1$  wt% H<sub>2</sub>
- TiN/Mg(BH<sub>4</sub>)<sub>2</sub>:  $7.1 / 14.9 = 50\%$  Capacity
- Reversibility TiN/Mg(BH<sub>4</sub>)<sub>2</sub> = 6.2 wt%
- @  $6.2 / 7.1 = 87\%$  efficiency! (?)
- Desorbed H<sub>2</sub> >> Binary hydrides (e.g. MgH<sub>2</sub> at 7.6 wt%)

ALD titanium nitride (TiN) is a promising new hydride additive!



# A&P: Reversibility via TiN coating shows a path to cycling (and *Phase 3*)

- No crystalline  $\text{Mg}(\text{BH}_4)_2$  (or other hydrides)
- Lots of irreversible  $\text{MgCl}_2$ ,  $\text{MgO}$ , etc.
- Rates Needed 480 °C and it still took a long time
- $\text{TiN}/\text{Mg}(\text{BH}_4)_2$  reversibility at high cycling efficiency
- **GNG & Phase 3: Find the metal hydride that TiN will enable cycling**

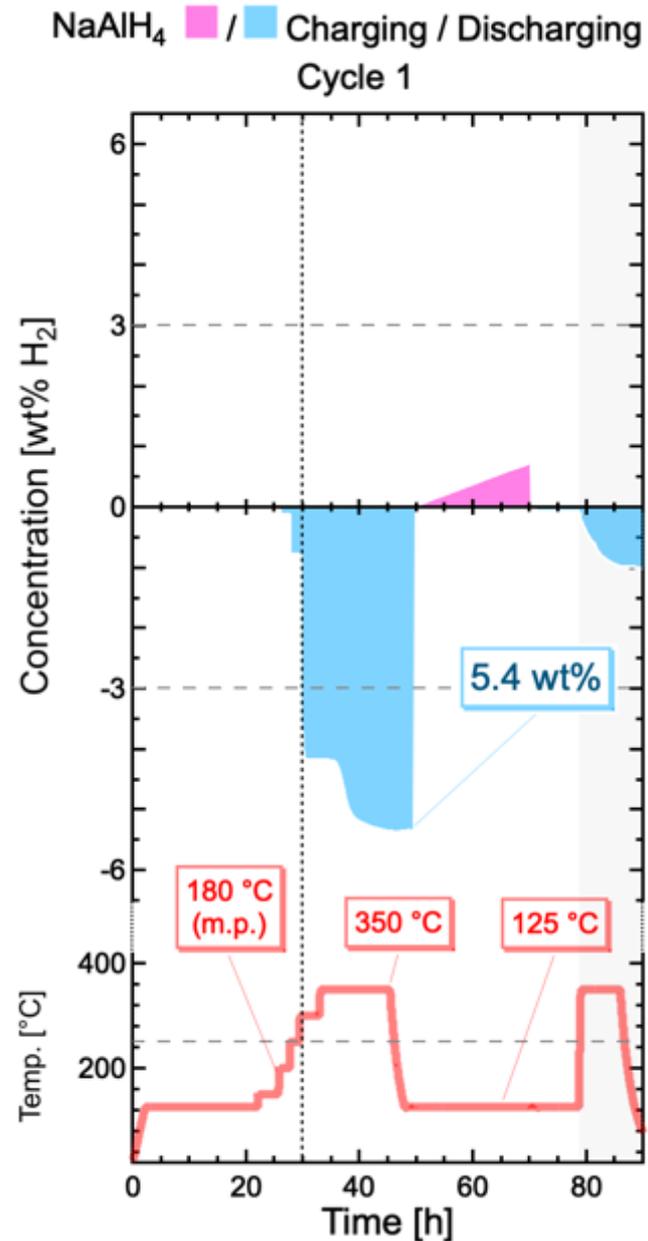


XRD: Metal Hydride Peaks:  $\ominus \square$   
 $\text{MgCl}_2$  ( $\text{MgBr}_2$ ),  $\text{MgO}$ , Amorphous:  $\checkmark$   
 (SSRL – N. Strange, M. Toney)

# A&P: Unmodified 'Neat' NaAlH<sub>4</sub> has Poor Rates

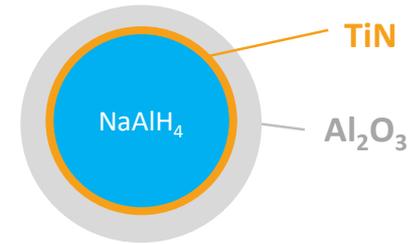
- Without additives (e.g. Ti)  
NaAlH<sub>4</sub> kinetics are too slow:
  - 5.4 wt% H<sub>2</sub> desorbed only  
after heating > 300 °C
- Absorption thermodynamics  
requires lower temperatures
  - Very little reversible cycling  
capacity observed
- Can an ALD TiN get NaAlH<sub>4</sub>  
to cycle?

Neat NaAlH<sub>4</sub> from Sigma Aldrich



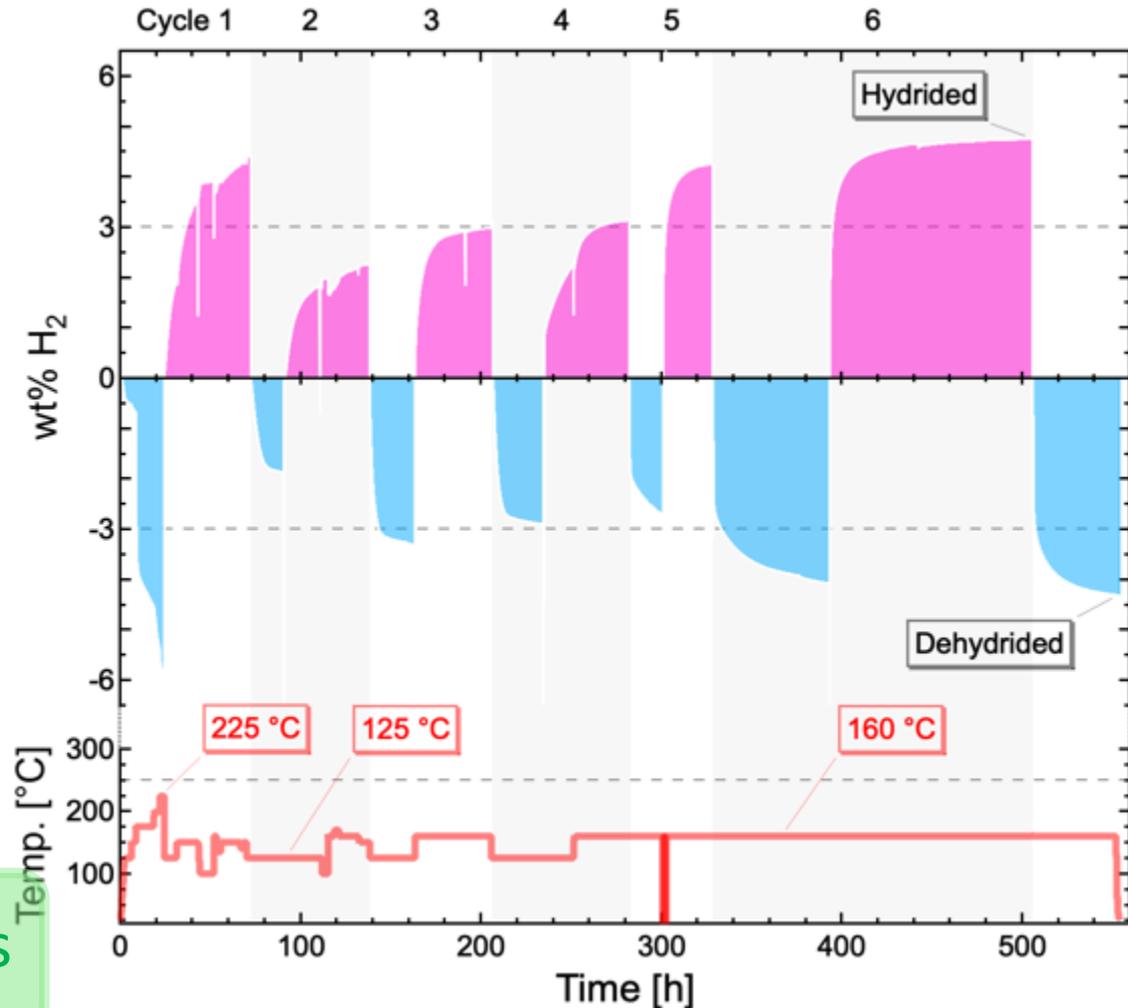
# A&P: H<sub>2</sub> cycling ALD- NaAlH<sub>4</sub> surpasses Phase 2 goal

ALD on NaAlH<sub>4</sub>  
(Sigma):  
1 nm TiN + 10 nm  
Al<sub>2</sub>O<sub>3</sub>



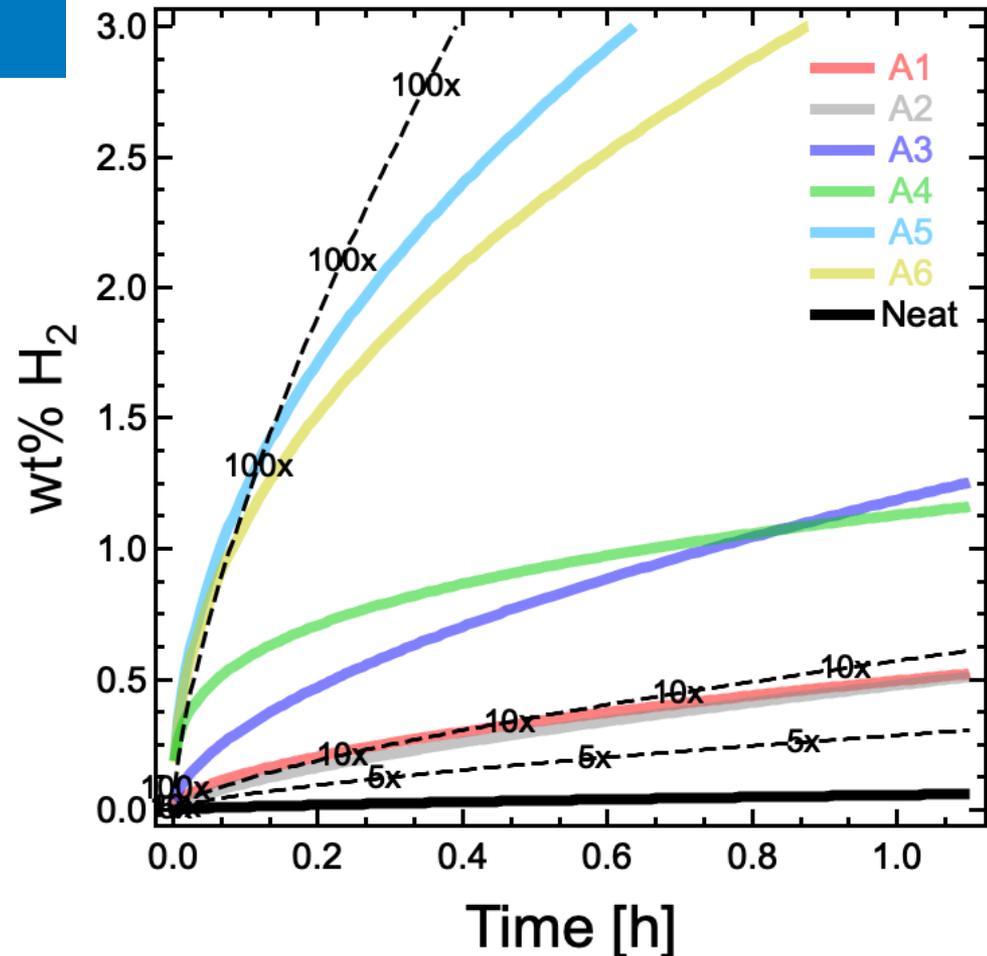
- PCT cycling:
  - 120 bar H<sub>2</sub>
  - 225 °C: -5.7 wt%: Full theoretical capacity
  - 160 °C (from 350 °C)
  - 6.5 cycles
- Reversibility:
  - -3.6/+3.8 wt% avg.
  - -4.3/+4.8 wt% best ✓

• Goal: 3 wt% @ 3 cycles



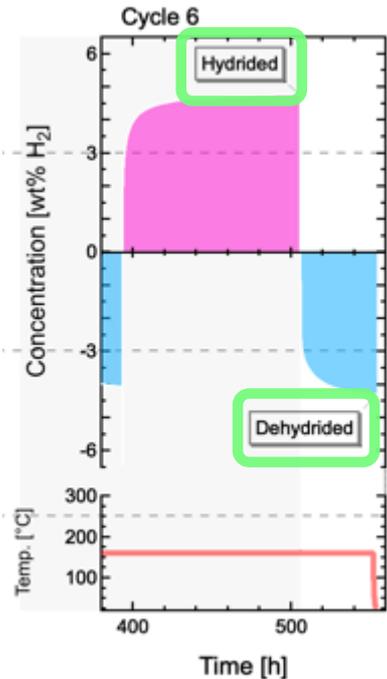
# A&P: Rates for ALD- $\text{NaAlH}_4$ exceed Phase II Goal

- Power Law Fits to  $\text{H}_2$  absorption rate  $v$ :
  - $v = k[\text{H}_2]^p$
  - Fitting for first 0.5 h
- Scalar multipliers to rate law of neat  $\text{NaAlH}_4$ 
  - 5x, 10x, 100x
- ALD coatings improve Absorption rates by 10-100x

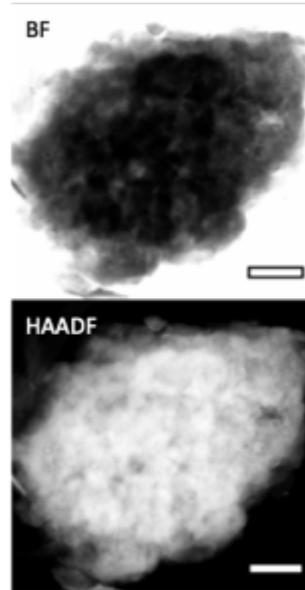


Rate analysis of absorption steps A1-6 for ALD- $\text{NaAlH}_4$  compared to Neat exceed the goal of 5x improvement. Temps. 125 °C: Neat, A1, A2; **160 °C:** A3, A4, A5, A6.

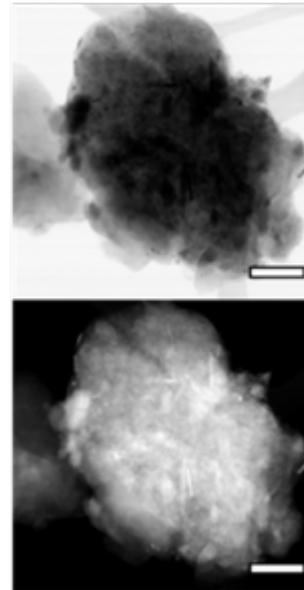
# A&P: Smooth, clean morphology evolves from cycling ALD- $\text{NaAlH}_4$



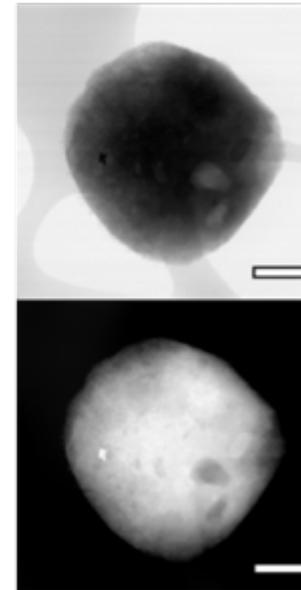
Neat  $\text{NaAlH}_4$   
As-received material



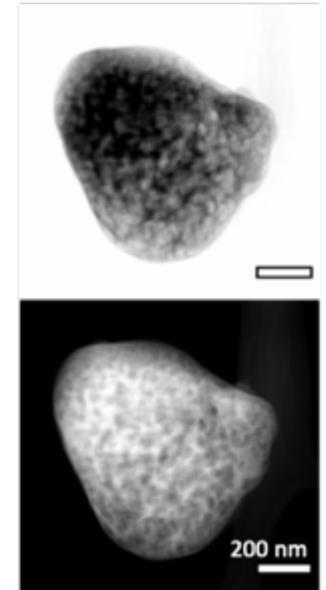
$\text{NaAlH}_4$  + ALD  
As-prepared material



$\text{NaAlH}_4$  + ALD +  $\text{H}_2$   
Hydrogenated, 6 cycles



$\text{NaAlH}_4$  + ALD -  $\text{H}_2$   
Dehydrogenated, 6.5 cycles



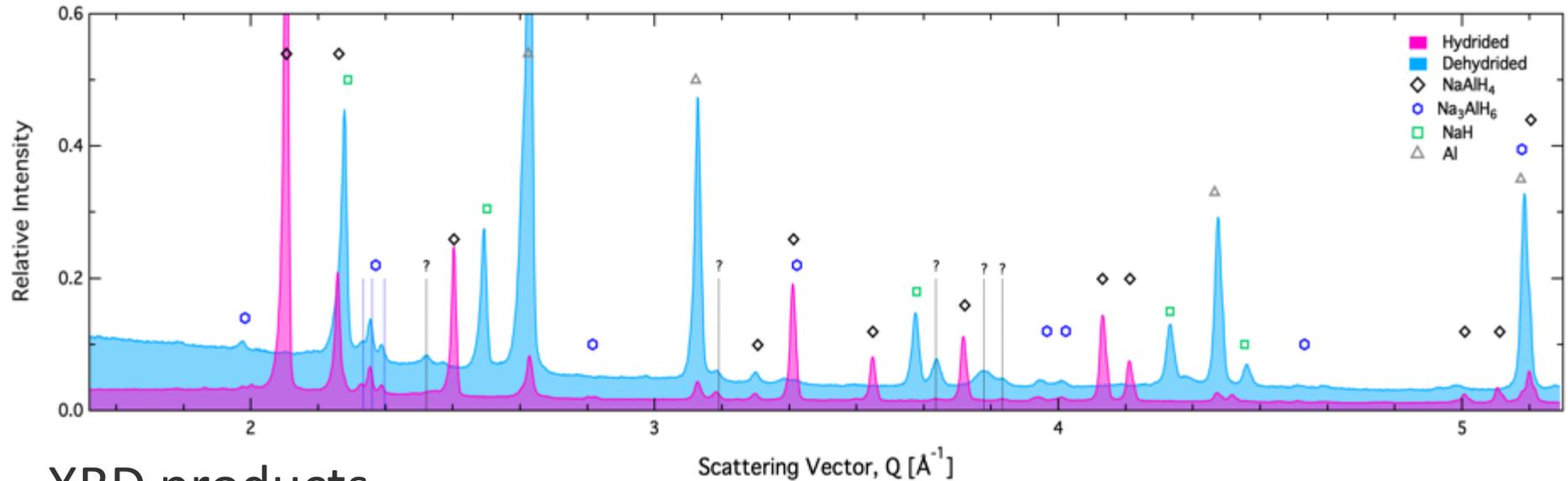
## TEM

- Desorption 1 > 180  $^{\circ}\text{C}$  (melting point)!
- Cycling  $\rightarrow$  smooth morphology
- **Particle size: 100s of nm, low particle agglomeration**

## XRF (not shown)

- Neat  $\text{NaAlH}_4$ , Ti? No
- Ti on ALD- $\text{NaAlH}_4$ ? Yes!
- **No detectable Cl**

# A&P: Efficient Cycling ALD- $\text{NaAlH}_4$ with high reversibility



## XRD products

- Dehydrided: Rxn {2}
- Hydrided: Rxn {1}

- **No Cl products**  
**(e.g. NaCl)**
- Reversibility: **80-85%**  
**of 5.6 wt%**  
**Cycling {1} + {2}**

$\text{NaAlH}_4$  ( 7.5 wt%  $\text{H}_2$  / 3.7 + 1.9 = 5.6 wt% reversible )

	Reaction	wt% $\text{H}_2$ (theoretical)	Sample	XRD	wt% $\text{H}_2$ (measured)
{1}	$\text{NaAlH}_4 \rightleftharpoons \frac{1}{3}\text{Na}_3\text{AlH}_6 + \frac{2}{3}\text{Al} + \text{H}_2$	3.7	Hydrided	<b><math>\text{NaAlH}_4</math>;</b> <b>Al,</b> <b><math>\text{Na}_3\text{AlH}_6</math></b> (trace)	+4.8
{2}	$\text{Na}_3\text{AlH}_6 \rightleftharpoons \text{NaH} + \text{Al} + 3/2\text{H}_2$	1.9	Dehydrided	<b><math>\text{NaH}</math>, <b>Al;</b></b> <b><math>\text{NaAl}_3\text{H}_6</math></b> (trace)	-4.3
{3}	$\text{NaH} \rightleftharpoons \text{Na} + \frac{1}{2}\text{H}_2$	1.8	No	<b>No Na</b>	

# Collaboration and Coordination

- H2 Technology Consulting LLC, prime partner, subcontractor, industry
  - Quantitative PCT measurements; Subject matter expertise
- Colorado School of Mines, Chemistry Department, subcontractor
  - Advanced materials characterization: atom probe tomography, TEM composition mapping
- HyMARC EMN, DOE FCTO
  - SNL: Nanostructured  $\text{Mg}(\text{BH}_4)_2$ , Subject matter expertise; high pressure experiments
  - NREL: Materials characterization, equipment, facilities, subject matter expertise
  - SLAC: X-ray scattering and spectroscopy
  - LLNL: Theory
  - PNNL: Advanced materials characterization; Subject matter expertise
- Forge Nano, ALD manufacturing company
  - Potential industry partner, letter of support



# Technology Transfer Activities

- Provisional patent: “Nanostructured Composite Metal Hydrides”, USPTO Application No. 62/507,354 was converted to a non-provisional patent USPTO Application No. 15/982,232.
- Pursuing potential partners for ALD scale-up (ForgeNano)
- Identifying other applications where this technology would solve technical problems

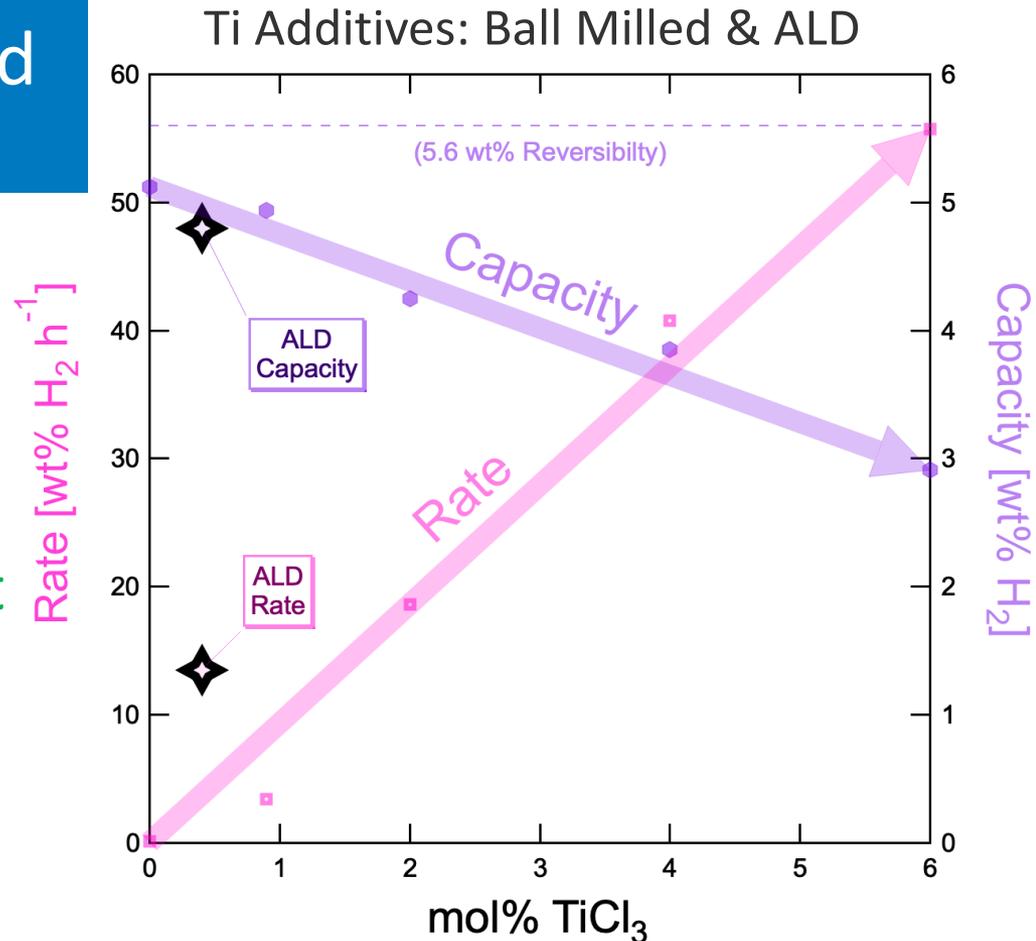
# Remaining Challenges and Barriers: How good is ALD- $\text{NaAlH}_4$ ?

## Rates:

- ALD- $\text{NaAlH}_4$  rate is an excellent start with efficient Ti loading
- A 10x increase from current levels is required for the DOE charging target

## Reversible Capacity:

- ALD- $\text{NaAlH}_4$  Reversibility Capacity is exceptional
- $\geq 5 \text{ wt}\% \text{ H}_2$  is needed for a pathway to technology

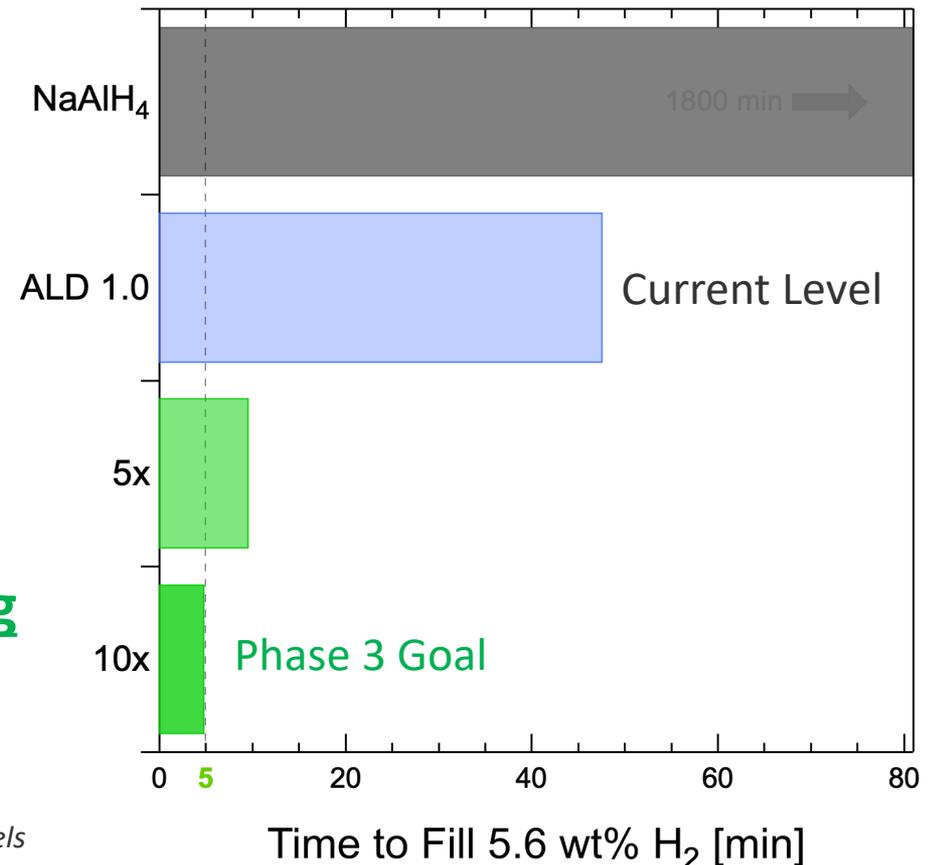
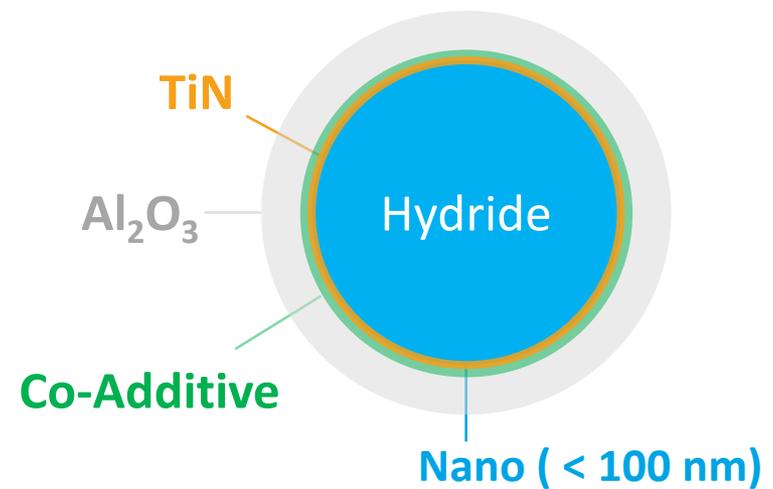


*Conventional balled milled Ti additives increase rate at the cost of reversible capacity:*

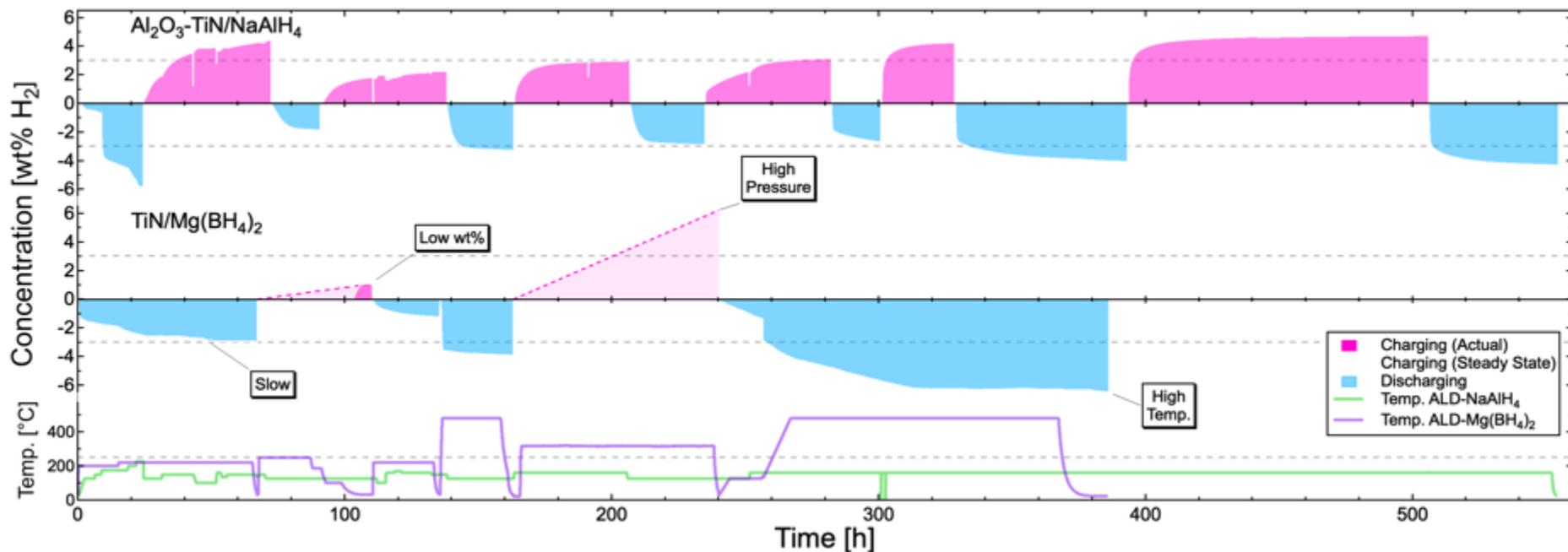


# Proposed Future Work: Increase Rates / Capacity

- Co-Additives: Ti + Fe\*
  - Increase Rate > 2x
  - Decrease Temperatures
  - \*Fe, Ni, Ce, Zr, Pd...
- Nano-size Hydride
  - Increase Rate > 5x+
  - Increase reversible capacity by control of reaction pathways
- Al<sub>2</sub>O<sub>3</sub> Coating
  - Improve Cycling, Handling
  - ALD Al<sub>2</sub>O<sub>3</sub> passivates w/o loss in capacity



# Summary



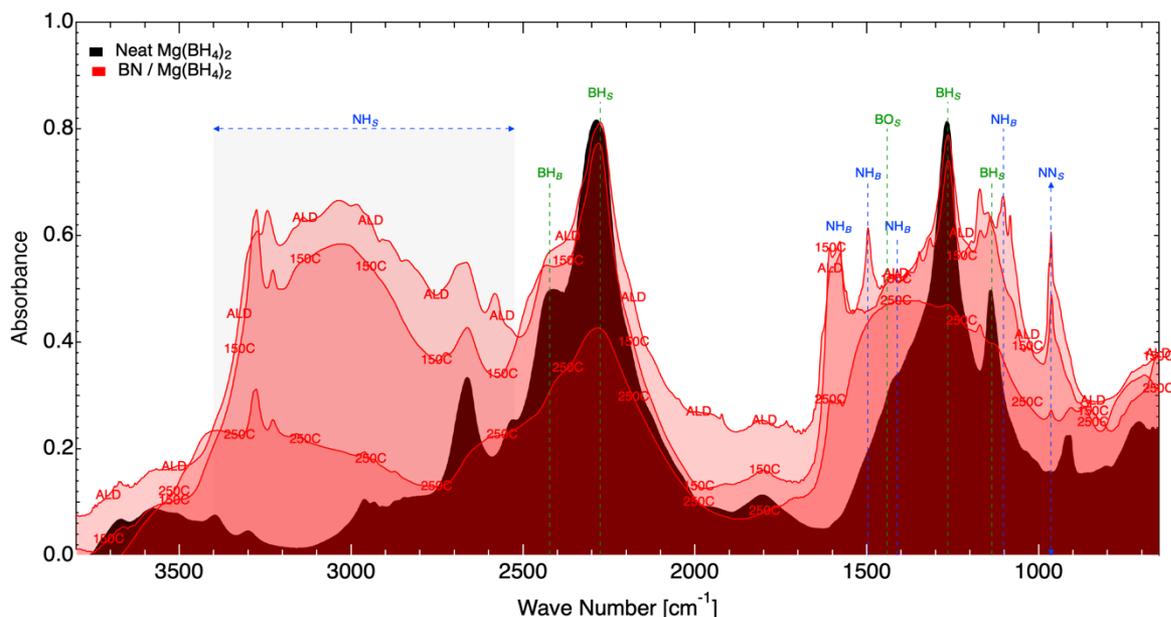
The best performers for Phase 1 and 2:  $\text{TiN/Mg(BH}_4)_2$ ;  $\text{Al}_2\text{O}_3\text{-TiN/NaAlH}_4$ .  
ALD  $\text{TiN}$  significantly improved rates, cycling *and* reversible capacity.

## Go/No-Go Phase 2

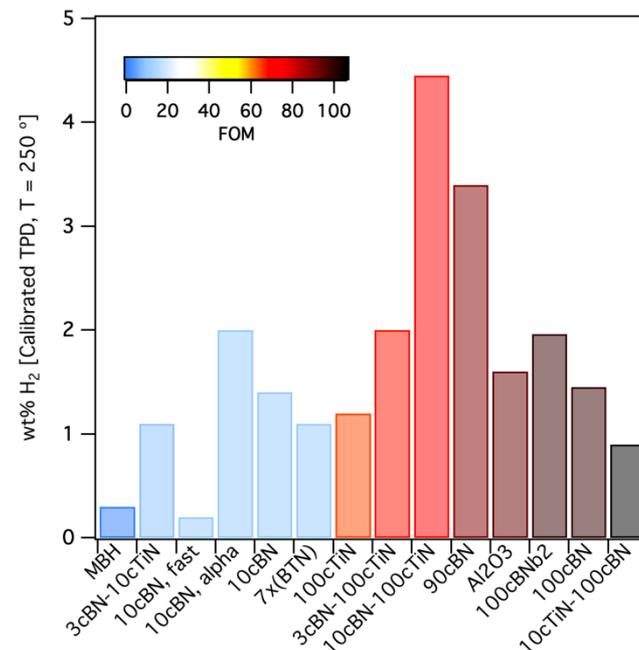
- $\pm 3$  wt%  $\text{H}_2$  reversible capacity, 3 cycles ✓ Surpassed
- 5-fold (5x) improvement of the absorption kinetics. ✓ Surpassed
- Operability:  $\leq 250$  °C,  $\leq 120$  bar  $\text{H}_2$  ✓ Met
- STRETCH 5 cycles,  $\pm 3$  wt% reversibility. ✓ Surpassed

# A&P: Responses to Previous Year Reviewers' Comments

- Previous year AMR reviews emphasized the need to understand the ALD 'BN' /  $\text{Mg}(\text{BH}_4)_2$  discharging mechanism and pointed to:
  - Potential reactions with  $\text{Mg}(\text{BH}_4)_2$  and ALD precursors
  - Spectroscopy to probe species like N-H, B-H
  - Systematic studies of ALD coatings on  $\text{Mg}(\text{BH}_4)_2$
- In response, over twenty new materials were synthesized and characterized with NMR, IR, XRD, TPD, and microscopy which resulted in the 'desorption mechanism' summarized in slide 5. Some highlights are given below.



**Left:** FTIR of changes to ALD BN/ $\text{Mg}(\text{BH}_4)_2$  after ALD, 150 °C, 250 °C where N-H and B-H reduce which points to the  $\text{H}^{\delta-} + \text{H}^{\delta+}$  reaction. **Right:** Figure of Merit (FOM) ranking potential of gravimetric penalties of ALD coatings to wt%  $\text{H}_2$  release. FOM does not show a dependence film thickness (BN, TiN cycles) which supports the  $\text{H}^{\delta-} + \text{H}^{\delta+}$  reaction.



$$FOM = (\text{BNcycles}) + \frac{\rho_{\text{TiN}} \text{GPC}_{\text{TiN}}}{\rho_{\text{BN}} \text{GPC}_{\text{BN}}} (\text{TiNcycles})$$

# Thank You

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[www.nrel.gov](http://www.nrel.gov)

Publication Number

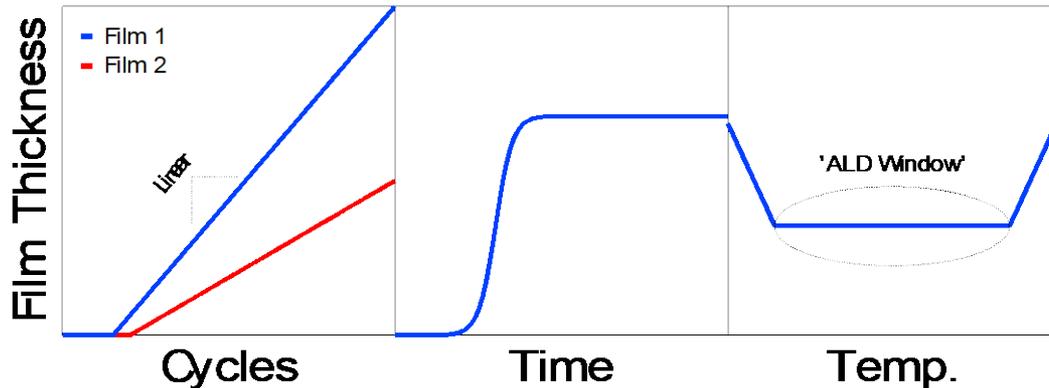
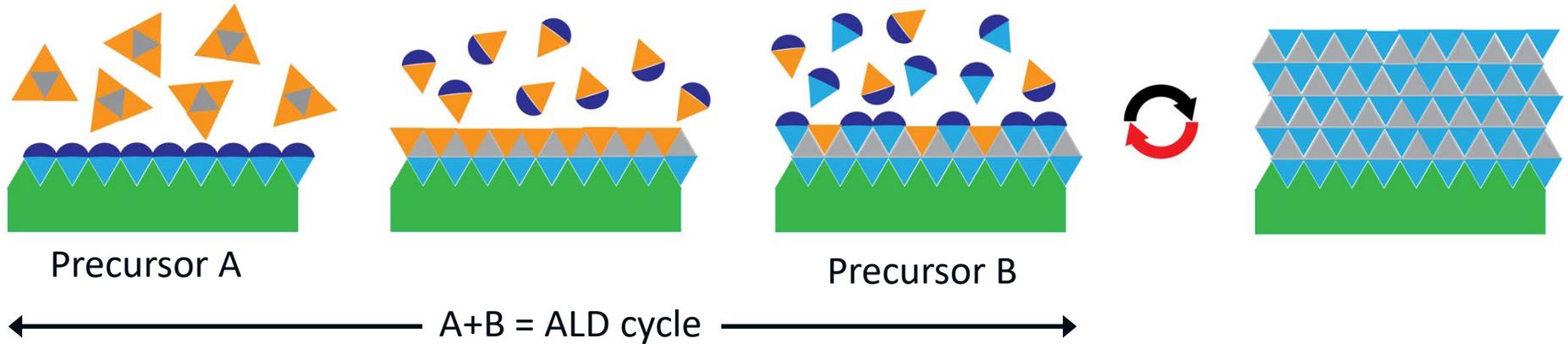
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# Technical Back-Up Slides

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# Atomic Layer Deposition



Nucleation and growth rate determined by surface chemistry and precursor molecular size.

Operating principles:

- ALD: sequential, self-limiting reactions at a surface
- Linear growth rate, saturating precursor adsorption, temperature-defined process window